

Title (en)

Method of manufacturing a metal oxide varistor and varistor made according to this method

Title (de)

Verfahren zum Herstellen eines Varistors auf Basis eines Metalloxids und ein nach diesem Verfahren hergestellter Varistor

Title (fr)

Procédé de fabrication d'une varistance à base d'oxide de metal et varistance fabriquée selon ce procédé

Publication

**EP 0955644 A3 20031217 (DE)**

Application

**EP 99810304 A 19990413**

Priority

DE 19820134 A 19980506

Abstract (en)

[origin: EP0955644A2] The varistor has a cylindrical body of resistive material that has a base of metal oxide. The end surfaces have electrodes (2,3) with an exposed section having a layer of electrode material (9). In a second stage the edge is formed with an angled surface.

IPC 1-7

**H01C 7/108**; **H01C 1/14**; **H01C 17/28**

IPC 8 full level

**H01C 1/14** (2006.01); **H01C 1/142** (2006.01); **H01C 7/108** (2006.01); **H01C 17/28** (2006.01)

CPC (source: EP US)

**H01C 1/142** (2013.01 - EP US); **H01C 7/108** (2013.01 - EP US); **H01C 17/28** (2013.01 - EP US); **Y10T 29/49082** (2015.01 - EP US); **Y10T 29/49101** (2015.01 - EP US)

Citation (search report)

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